## **SUPPORTING INFORMATION**

## Dimethyl amino phenyl substituted Silver Phthalocyanine as UV- and Visible-Light Absorbing Photoinitiator: *In-situ* Preparation of Silver/Polymer Nanocomposites

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Figure S1. <sup>1</sup>H-NMR spectrum of 1



Figure S2. <sup>13</sup>C-NMR spectrum of 1



Figure S3. FT-IR spectrum of 1.



Figure S4. MALDI-TOF spectrum of 1



Figure S5. FT-IR spectra of (1), dmaph-Ag<sup>(II)</sup>Pc and dmaph-H<sub>2</sub>Pc.



Figure S6. MALDI-TOF spectrum of dmaph-H<sub>2</sub>Pc



Figure S7. <sup>1</sup>H-NMR spectrum of dmaph-H<sub>2</sub>Pc-nHCl



Figure S8. MALDI-TOF spectrum of dmaph-Ag<sup>(II)</sup>Pc.



Figure S9. UV-Vis spectra of dmaph-Ag<sup>(II)</sup>Pc and dmaph-H<sub>2</sub>Pc in CHCl<sub>3.</sub>



Figure S10. Selected MOs of dmaph-H<sub>2</sub>Pc obtained by B3LYP method.



**Figure S11.** Photolysis of A) **dmaph-Ag**<sup>(II)</sup>**Pc** and B) **dmaph-Ag**<sup>(II)</sup>**Pc**/Iod under LED@405nm irradiation. LED@405 nm intensity = 390 mW/cm<sup>2</sup>. [Iod] =  $7.9 \times 10^{-5}$  M, [**dmaph-Ag**<sup>(II)</sup>**Pc**] =  $3.8 \times 10^{-5}$  M. Solvent = CHCl<sub>3</sub>.



**Figure S12.** A), B) and C) TEM images of Ag NPs after irradiation (LED@385 nm) of **dmaph-Ag**<sup>(II)</sup>**Pc**/Iod photoinitiating system in CHCl<sub>3</sub>. D) Particule size diameter (in nm) and E) EDX spectrum of Ag NPs. [**dmaph-Ag**<sup>(II)</sup>**Pc**] =  $3.9 \times 10^{-5}$  M and [Iod] =  $8.4 \times 10^{-5}$  M.



Figure S13. A) and B) TEM images of Ag NPs after irradiation (LED@385 nm) of dmaph-Ag<sup>(II)</sup>Pc in CHCl<sub>3</sub>. C) EDX spectrum of Ag NPs. [dmaph-Ag<sup>(II)</sup>Pc] =  $3.9 \times 10^{-5}$  M.



Figure S14. Photolysis of dmaph-Ag<sup>(II)</sup>Pc/Iod/RhB under LED@385nm irradiation. LED@385 nm intensity = 470 mW/cm<sup>2</sup>. [dmaph-Ag<sup>(II)</sup>Pc] =  $1.4 \times 10^{-5}$  M. [Iod] =  $7.9 \times 10^{-5}$  M. [RhB] =  $2.3 \times 10^{-6}$  M. Solvent = CHCl<sub>3</sub>.



Figure S15. Cyclic voltammograms of dmaph-Ag<sup>(II)</sup>Pc in a mixed solvent CHCl<sub>3</sub>/ACN (80/20 v/v) + 5 × 10<sup>-2</sup> M *n*Et<sub>4</sub>BF<sub>4</sub> measured at a scan rate of 25 mV.s<sup>-1</sup>. [dmaph-Ag<sup>(II)</sup>Pc] = 10<sup>-4</sup> M.



**Figure S16**. Kinetic profiles of TMPTA in laminate with **dmaph-Ag**<sup>(II)</sup>**Pc** (0.25 wt%) and **dmaph-Ag**<sup>(II)</sup>**Pc**/Iod (0.25%/2.5% w/w) under LED exposure. 1) **dmaph-Ag**<sup>(II)</sup>**Pc**/TMPTA upon LED@385 nm, 2) **dmaph-Ag**<sup>(II)</sup>**Pc**/TMPTA upon LED@405 nm, 3) **dmaph-Ag**<sup>(II)</sup>**Pc**/Iod/TMPTA upon LED@385 nm and 4) **dmaph-Ag**<sup>(II)</sup>**Pc**/Iod/TMPTA upon LED@405 nm.



**Figure S17**. Kinetics of ring-opening polymerization of EPOX/CHO (50%/50% w/w) under air with **dmaph-Ag**<sup>(II)</sup>**Pc** (0.25%wt) upon LEDs irradiation at 385 nm (130 mW/cm<sup>2</sup>) and at 405 nm (160 mW/cm<sup>2</sup>).



**Figure S18**. Kinetics of photopolymerization of EPOX/CHO (50/50 wt%) under air with **dmaph-Ag**<sup>(II)</sup>**Pc**/Iod (0.25%/2.5% w/w) under 1) LED@385 nm, 2) LED@405 nm exposure and with **dmaph-H2Pc**/Iod (0.25%/2.5% w/w) under 3) LED@385 nm and 4) LED@405 nm. Intensities of LED@385 nm and LED@405 nm are respectively 130 and 160 mW/cm<sup>2</sup>.



**Figure S19**. Kinetics of photopolymerization of EPOX/CHO (50/50 wt%) under air with **dmaph-H2Pc** alone (0.25 wt%) under 1) LED@385 nm, 2) LED@405 nm exposure and with **dmaph-H2Pc**/Iod (0.25%/2.5% w/w) under 3) LED@385 nm and 4) LED@405 nm. Intensities of LED@385 nm and LED@405 nm are respectively 130 and 160 mW/cm<sup>2</sup>.



**Figure S20**. Kinetic profiles of TMPTA in laminate with **dmaph-H2Pc** (0.25 wt%) and **dmaph-H2Pc**/Iod (0.25%/2.5% w/w) under LED exposure. 1) **dmaph-H2Pc**/TMPTA upon LED@385 nm, 2) **dmaph-H2Pc**/TMPTA upon LED@405 nm, 3) **dmaph-H2Pc**/Iod/TMPTA upon LED@385 nm and 4) **dmaph-H2Pc**/Iod/TMPTA upon LED@405 nm. Intensities of LED@385 nm and LED@405 nm are respectively 130 and 160 mW/cm<sup>2</sup>.



**Figure S21.** Kinetic profiles of the system **dmaph-Ag**<sup>(II)</sup>**Pc**/Iod/EPOX/CHO/TMPTA (0.25%/2.5%/33%/33%/33% w/w/w/w) in laminate. Epoxy and acrylate conversions of EPOX/CHO (curves 1 and 2) and TMPTA (curves 3 and 4) respectively with **dmaph-Ag**<sup>(II)</sup>**Pc**/Iod (0.25%/2.5% w/w) photoinitiating system upon LEDs irradiation at 385 nm (130 mW/cm<sup>2</sup>, curves 1 and 3) and at 405 nm (160 mW/cm<sup>2</sup>, curves 2 and 4).



Figure S22. Kinetic profiles of the system  $dmaph-Ag^{(II)}Pc/Iod/EPOX/CHO/TMPTA$  (0.25%/2.5%/33%/33%/33% w/w/w/w) under air. Epoxy and acrylate conversions of EPOX/CHO (curves 1 and 2) and TMPTA (curves 3 and 4) respectively with dmaph-

**Ag**<sup>(II)</sup>**Pc**/Iod (0.25%/2.5% w/w) photoinitiating system upon LEDs irradiation at 385 nm (130 mW/cm<sup>2</sup>, curves 1 and 3) and at 405 nm (160 mW/cm<sup>2</sup>, curves 2 and 4).



Figure S23. Structure of the radical cation dmaph-Ag<sup>(II)</sup>Pc<sup>++</sup>